

**IN THE SPECIFICATION:**

Please replace paragraph [0003] with the following amended paragraph:

[0003] Epoxy-based resins are generally photochemically cured by adding an onium salt photoinitiator to the epoxy-based resin and exposing the resulting formulation to UV radiation. The UV radiation photolyzes the photoinitiator to generate an acid, such as hexafluoroantimonic acid ( $\text{HSbF}_6$ ), hexafluorophosphoric acid ( $\text{HPF}_6$ ), tetrafluoroboric acid ( $\text{HBF}_4$ ), or triflic acid ( $\text{CF}_3\text{SO}_3\text{H}$ ), that yields a proton that attacks the oxirane oxygen of the epoxy group and results in cationic curing of the epoxy-based resin. Onium salt photoinitiators that generate hexafluoroantimonic acid are preferred, as hexafluoroantimonic acid typically cures epoxy-based resins ~~fasters~~ faster than other acids that have been tested.